

L Number	Hits	Search Text	DB	Time stamp
1	58453	anhydrous and oxide	USPAT; JPO; DERWENT	2002/01/22 17:55
2	2449	(anhydrous and oxide) and (hydrogen adj fluoride)	USPAT; JPO; DERWENT	2002/01/22 17:56
3	519	((anhydrous and oxide) and (hydrogen adj fluoride)) and steam	USPAT; JPO; DERWENT	2002/01/22 17:56
4	52	((anhydrous and oxide) and (hydrogen adj fluoride)) and steam and substrate and (dop\$4 or implant\$6 or impurit\$5)	USPAT; JPO; DERWENT	2002/01/22 17:57
5	45	((((anhydrous and oxide) and (hydrogen adj fluoride)) and steam) and substrate and (dop\$4 or implant\$6 or impurit\$5)) and temperature and flow	USPAT; JPO; DERWENT	2002/01/22 17:58
6	33	(((((anhydrous and oxide) and (hydrogen adj fluoride)) and steam) and substrate and (dop\$4 or implant\$6 or impurit\$5)) and temperature and flow) and flow adj rate	USPAT; JPO; DERWENT	2002/01/22 17:58
8	0	((((((anhydrous and oxide) and (hydrogen adj fluoride)) and steam) and substrate and (dop\$4 or implant\$6 or impurit\$5)) and temperature and flow) and flow adj rate) and (thermal adj oxid\$6)) and gate adj oxide	USPAT; JPO; DERWENT	2002/01/22 18:01
7	6	((((((anhydrous and oxide) and (hydrogen adj fluoride)) and steam) and substrate and (dop\$4 or implant\$6 or impurit\$5)) and temperature and flow) and flow adj rate) and (thermal adj oxid\$6)	USPAT; JPO; DERWENT	2002/01/22 18:01